

Evidence for identification of divacancy oxygen center in high purity oxygenated Si

G.Alfieri*, E.V.Monakhov*, B.S.Avset, B.G.Svensson***

***Department of Physics, Physical Electronics, University of
Oslo, P.O. Box 1048 Blindern, N-0316 Oslo, Norway**

****SINTEF, Electronics and Cybernetics, PO Box 124 Blindern, N-0314
Oslo, Norway**



- ✓ Experimental details
 - samples characteristics

- ✓ Results and discussion
 - SIMS data*
 - DLTS data

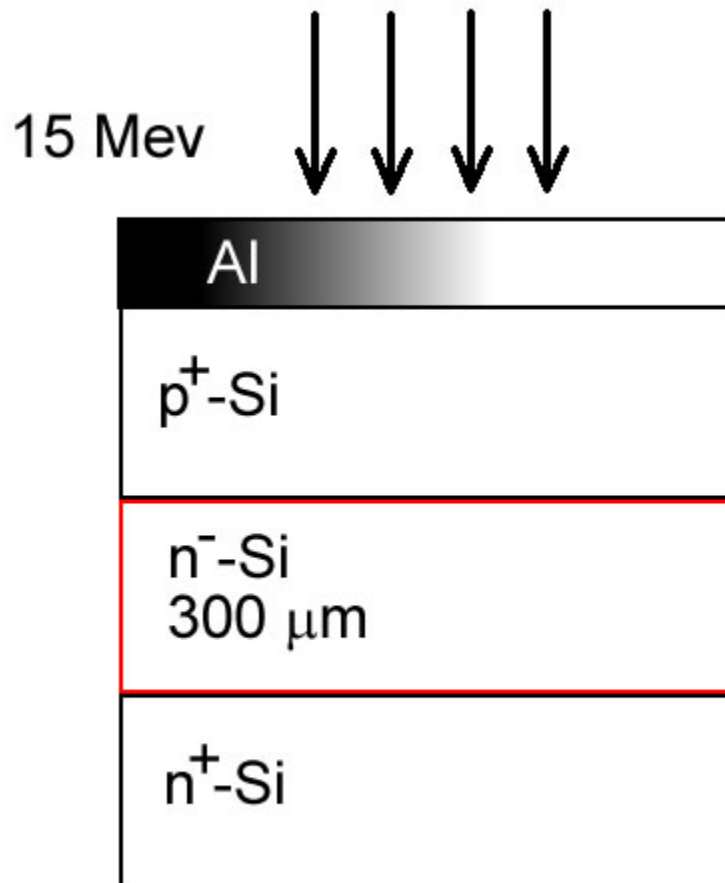
- ✓ Conclusion

*Performed at SINTEF



3 $p^+n\text{-}n^+$ diodes were made using high-resistivity high purity FZ-Si

Sample	Doping	Oxidation process	Oxygenation process
A	$5 \times 10^{12} \text{ P/cm}^3$	21h dry oxidation at 1200°C	80h in N_2 at 1150°C
B	$4 \times 10^{12} \text{ P/cm}^3$	21 h dry oxydation at 1200°C	---
C	$3 \times 10^{12} \text{ P/cm}^3$	3.7h and wet oxidation at 1100°C	---

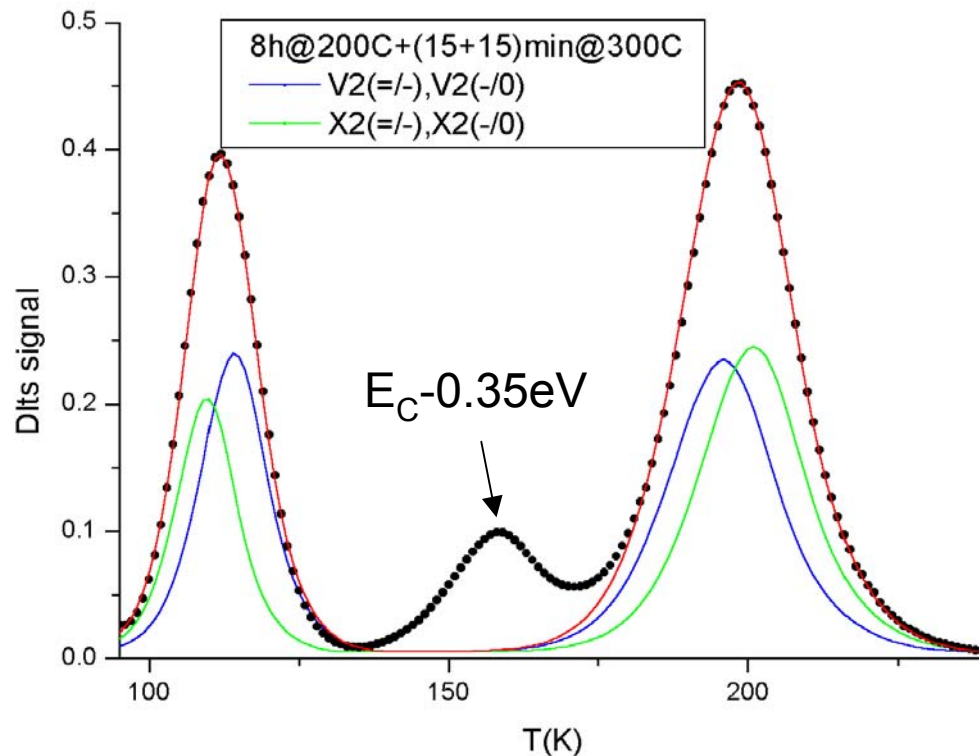


- ✓ The diodes were irradiated at RT
- ✓ 15-MeV electrons beam
- ✓ Dose of $4 \times 10^{12} \text{ cm}^{-2}$



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- ✓ 7-MeV protons irradiated FZ-Si
- ✓ Some wafers received oxygenation treatment ($[O] \sim 10^{17} \text{cm}^{-3}$)

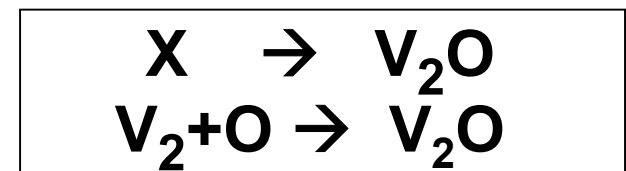


transformation observed

$V_2(=/-)$	$\rightarrow$	$X(=/-)$
$E_c - 0.237 \text{eV}$		$E_c - 0.232 \text{eV}$
$1.3 \times 10^{-16} \text{cm}^2$		$1.3 \times 10^{-16} \text{cm}^2$

$V_2(0/-)$	$\rightarrow$	$X(0/-)$
$E_c - 0.43 \text{eV}$		$E_c - 0.47 \text{eV}$
$3.1 \times 10^{-15} \text{cm}^2$		$9.6 \times 10^{-15} \text{cm}^2$

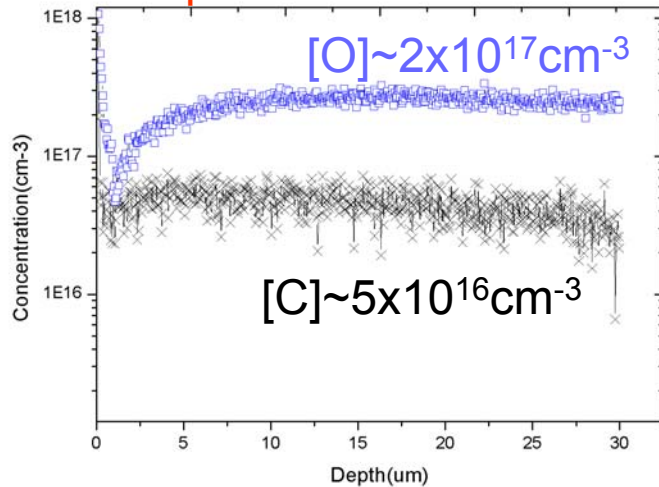
possible explanation



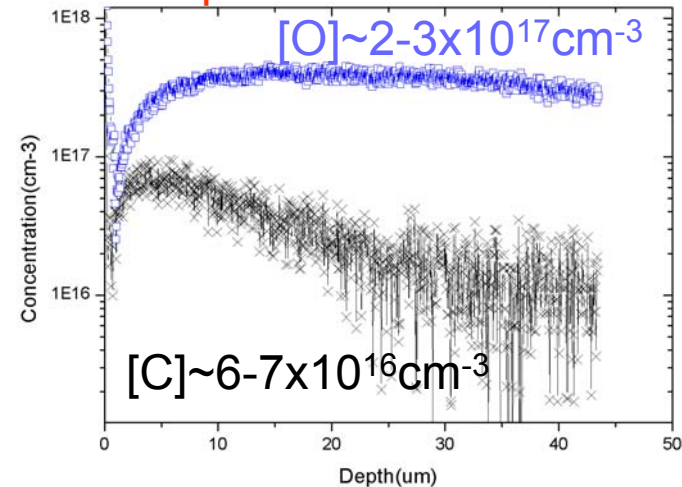


SIMS data for sample A,B,C

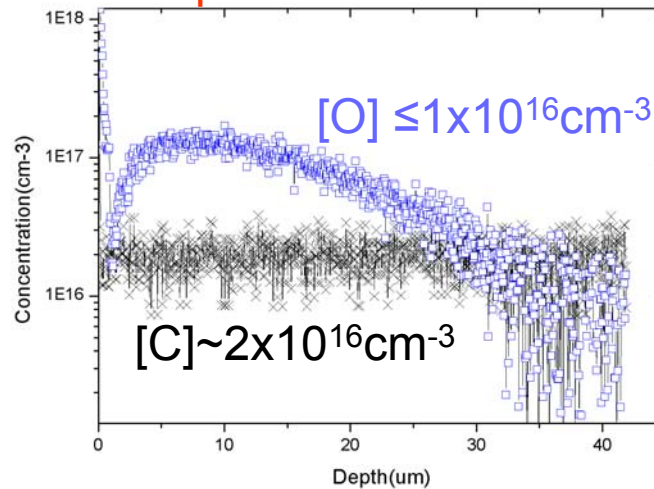
sample A



sample B

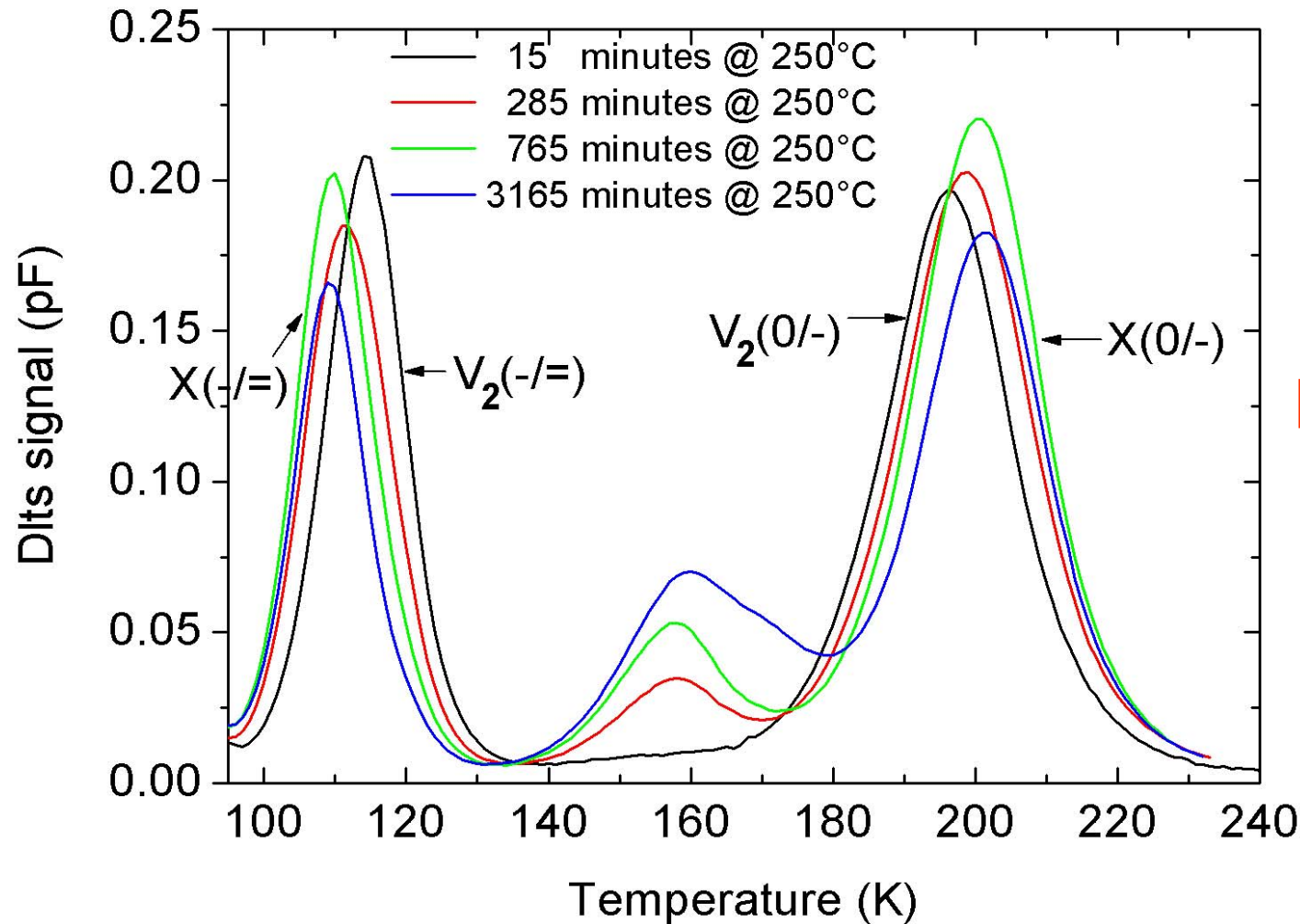


sample C



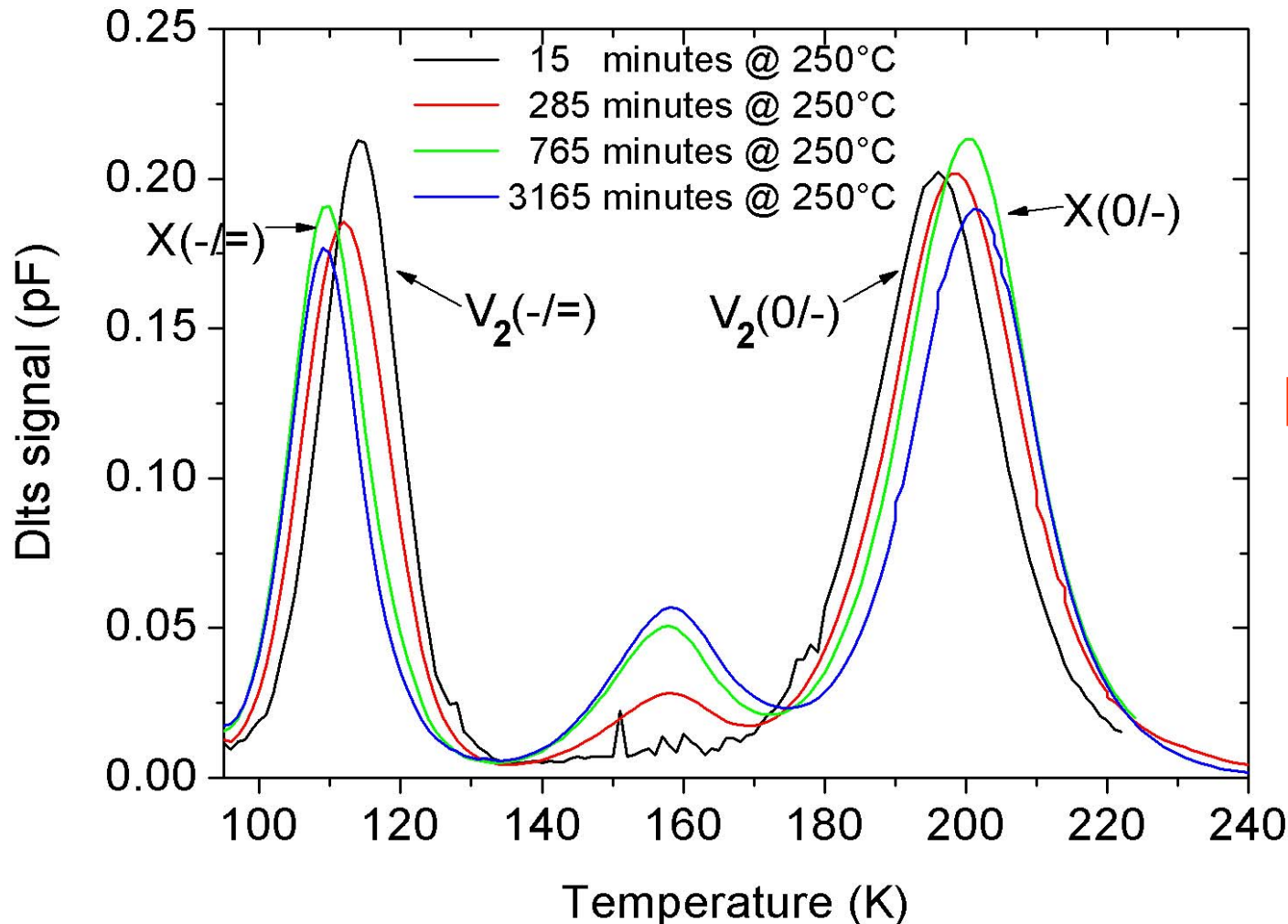


DLTS spectrum of Sample A



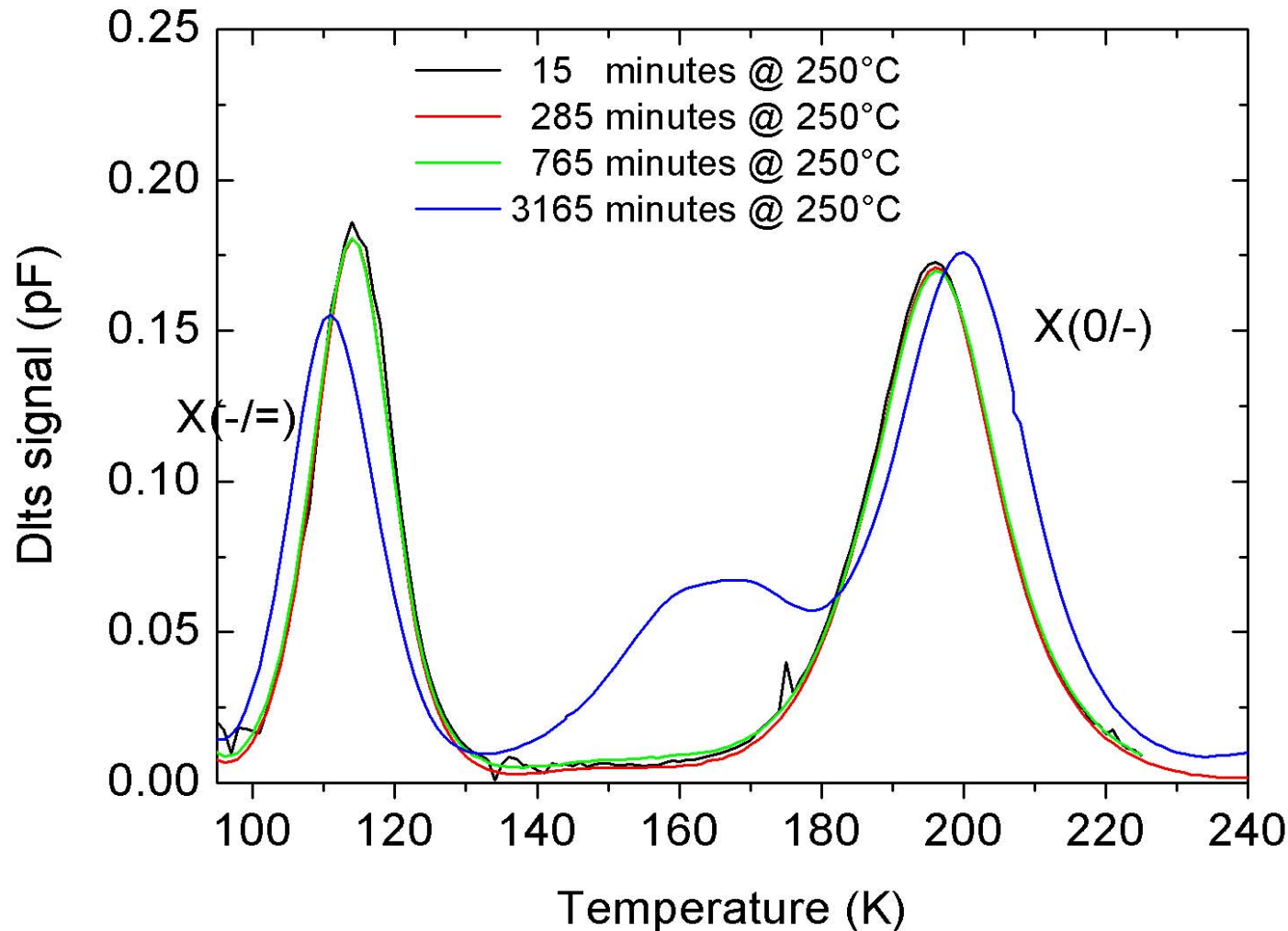


DLTS spectrum of Sample B





DLTS spectrum of Sample C



LOW [O]



- Both in proton and electron irradiated samples the same results have been found.
- The results of the annealing study show that the transformation of V_2 into X occurs at a rate that is directly correlated with oxygen content.
- This observation supports our previous tentative identification of X as V_2O which is formed through the interaction of migrating V_2 with an interstitial oxygen: $V_2 + O_i \rightarrow V_2O$



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